



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE *REC'D 12/2000*

In re: PATENT APPLICATION of
Inventor(s) Van Hamont, et al.

Appln. No.: 08/698,896 (U.S. Patent No. 5,705,197)
Issued January 1, 1998

Group Art Unit: 1617

Reissue Filed: January 6, 2000

Examiner: T. Criares

Title: HYBRID SOLVENT EVAPORATION-EXTRACTION PROCESS FOR
PRODUCING PLGA MICROSPHERES

Date: August 9, 2000

RESPONSE TO OFFICE ACTION

Hon. Commissioner of Patents and Trademarks
Washington, DC 20231

Sir:

In response to the Office Action dated June 30, 2000, please consider the following remarks.

Remarks

Reconsideration and allowance of the subject application are respectfully requested.

In the June 30 Office Action, the Examiner stated that the reissue oath/declaration filed with the application on January 6, 2000 was defective because it failed to identify at least one error which is relied upon to support the reissue application. Specifically, on page 2 of the Action the Examiner stated:

There is a failure in the declaration to identify and specify the errors relied upon and how they arose. Applicant merely states at page 2, first full paragraph of the declaration:

"In particular, we believe that the claims as issued are too narrow given the breadth of the disclosure in the specification. We believe that this was the result of our patent attorney's failure to appreciate the full scope of the invention."